

FEB 25 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Maldei, et al. Docket No.: INTECH 3.0-083 (02P15183US)  
Serial No.: 10/619,884 Art Unit: 2823  
Filed: July 15, 2003 Examiner: Brook Kebede  
Title: Method to Improve Bitline Contact Formation Using a Line Mask

Mail Stop: Amendment  
Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT ACCOMPANYING RCE

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed December 1, 2004. Please amend the above-referenced application as follows. This amendment is accompanied by an RCE document.